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INFORMATION DISCLOSURE STATEMENT						CT/JP2004/0073 .0/560,58	50	
(Use several sheets if necessary)				APPLICANTS Masahiro SAKURADA et al.				
				FILING DATE December 13, 2005				
		U.S.	PATENT DO	CUMENTS				
EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME		CLASS	SUB CLASS	
FOREIGN PATENT DOCUMENTS								
		DOCUMENT NUMBER	DATE	COUNTRY	ď	CLASS	SUB CLASS	
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/F.H./	2	JP A 08-268794 w/abst. & trans	10/15/1996	JAPAN				
/F.H./	3	JP A 08-330316 w/abst. & trans	12/13/1996	JAPAN				
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EXAMINER	/Felisa Hiteshew/ DATE CONSIDERED 03/18/2008							
Examiner: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.								

Date: December 13, 2005